



ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

February 27, 2025	
IGI Report Number	LG685542560
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	CUT CORNERED RECTANGULAR MODIFIED BRILLIANT
Measurements	13.18 X 8.93 X 6.01 MM

GRADING RESULTS

Carat Weight	6.09 CARATS
Color Grade	F
Clarity Grade	VS 1

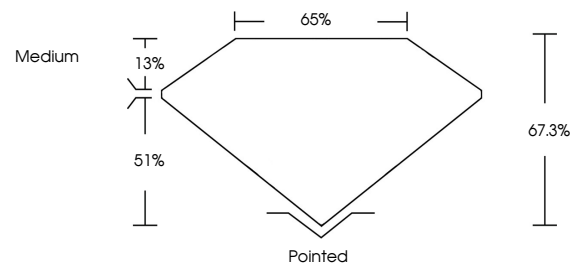
ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	 LG685542560

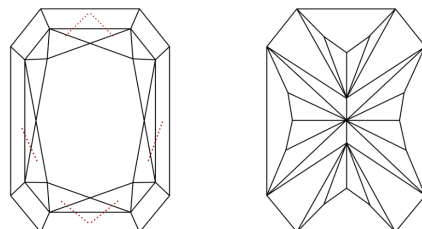
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
Type IIa

LG685542560
Report verification at lgi.org

PROPORTIONS

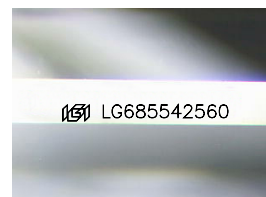


CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.



Sample Image Used

COLOR

D E F G H I J Faint Very Light Light

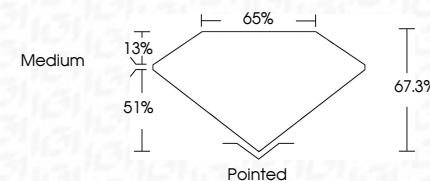
CLARITY

IF	VS ¹⁻²	VS ¹⁻²	SI ¹⁻²	I ¹⁻³
Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included

LABORATORY GROWN DIAMOND REPORT



February 27, 2025	
IGI Report Number	LG685542560
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	CUT CORNERED RECTANGULAR MODIFIED BRILLIANT
Measurements	13.18 X 8.93 X 6.01 MM
GRADING RESULTS	
Carat Weight	6.09 CARATS
Color Grade	F
Clarity Grade	VS 1



ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	 LG685542560
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	
Type IIa	



© IGI 2020, International Gemological Institute

FD - 10 20



THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK, BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES

www.igi.org

February 27, 2025	GI Report No. LG98502650	2009
CUT CORNERED RECT. MODIFIED BRILLIANT		2009
6.09 CARATS	VS 1	67.3%
		65%
	Medium	
	Pointed	
	EXCELLENT	
	EXCELLENT	
	NONE	
	1691 LG98502650	

Comments:

Chemical Vapor Deposition was created by Chemical Vapor Deposition (CVD) growth process.

Type IIa